PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q85504

Heiji WATANABE, et al.

Appln. No.: 10/519,084

Group Art Unit: 2822

Confirmation No.: 7332

Examiner: Tsz K. CHIU

Filed: December 23, 2004

For: SEMICONDUCTOR DEVICE AND ITS MANUFACTURING METHOD

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. §§ 1.97 and 1.98

MAIL STOP AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with the duty of disclosure under 37 C.F.R. § 1.56, Applicant hereby notifies the U.S. Patent and Trademark Office of the documents which are listed on the attached PTO/SB/08 A & B (modified) form and/or listed herein and which the Examiner may deem material to patentability of the claims of the above-identified application.

- 1. H.J. CHO, et al; Novel Nitrogen Profile Engineering for Improved TaN/HfO₂/Si MOSFET Performance; Microelectronic Research Center; pp.30.2.1-4; Austin, TX (previously submitted and considered)
- 2. Hyungsuk Jung et al., Electrical and Reliability Characteristics of a n U1trastjom TaOxNy Gate Deielectric Prepared by ND3 Annealing of Ta205, IEEE Electron Device Letters, December 2000, Vol. 21, No. 12, pp. 563-565
- 3. Japanese Patent Application Publication No. 2002-060944, published February 28, 2002 (previously submitted and considered).
- 4. Japanese Patent Application Publication No. 10-242461, published September 11, 1998 (previously submitted and considered).

INFORMATION DISCLOSURE STATEMENT

U.S. Appln. No.: 10/519,084

5. M. KOYAMA, et al; Thermally Stable Ultra-Thin Nitrogen Incorporated ZrO₂
Gate Dielectric Prepared by Low Temperature Oxidation of ZrN; IEEE Meeting;
Dec. 2001; pp. 20.3.1-4;; Washington, DC (previously submitted and considered).

Attorney Docket No.: Q85504

- 6. Japanese Patent Application Publication No. 2002-164343, published June 7, 2002 (previously submitted and considered).
- 7. Japanese Patent Application Publication No. 2000-195856, published July 14, 2000.
- 8. Japanese Patent Application Publication No. 2002-299607, published October 11, 2002, which corresponds to Japanese Patent Application Publication No. 2001-094052 (previously submitted and considered).
- 9. Japanese Patent Application Publication No. 2005-534163, published November 10, 2005, which corresponds to Japanese Patent Application Publication No. 2003-577313.
- Japanese Patent Application Publication No. 2003-282873, published October 3, 2003, which corresponds to Japanese Patent Application Publication No. 2002-080316.
- 11. Japanese Patent Application Publication No. 2003-8005, published January 10, 2003, along with English Language Abstract.
- 12. Japanese Patent Application Publication No. 2000-3885, published January 7, 2000, along with English Language Abstract.

One copy of each of the listed documents is submitted herewith, except for the following references that have been previously submitted and considered.

The present Information Disclosure Statement is being filed after the later of three months from the application's filing date and the mailing date of the first Office Action on the merits, but before a Final Office Action, Notice of Allowance, or an action that otherwise closes prosecution in the application (whichever is earlier), and therefore Applicant is filing concurrently herewith a Statement Under 37 C.F.R. § 1.97(e). No fee under 37 C.F.R. § 1.17(p) is required.

In compliance with the concise explanation requirement under 37 C.F.R. § 1.98(a)(3) for foreign language documents, Applicant encloses here with a copy of a corresponding Japanese

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Office Action dated June 27, 2007, and an English translation of the pertinent portions thereof

which cites such documents and indicates the degree of relevance found by the foreign office.

The submission of the listed documents is not intended as an admission that any such

document constitutes prior art against the claims of the present application. Applicant does not

waive any right to take any action that would be appropriate to antedate or otherwise remove any

listed document as a competent reference against the claims of the present application.

The USPTO is directed and authorized to charge all required fees, except for the Issue

Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any

overpayments to said Deposit Account.

Respectfully submitted,

/Howard L. Bernstein/

Howard L. Bernstein Registration No. 25,665

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WASHINGTON OFFICE

23373 CUSTOMER NUMBER

Date: September 12, 2007

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STATEMENT UNDER 37 C.F.R. § 1.97(e)

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

The undersigned hereby states, upon information and belief:

Except as otherwise noted in the Information Disclosure Statement for items cited and considered in an earlier Information Disclosure Statement, that each item of information contained in the Information Disclosure Statement filed concurrently herewith was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of said Information Disclosure Statement.

Respectfully submitted,

/Howard L. Bernstein/

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CUSTOMER NUMBER

Date: September 12, 2007

Howard L. Bernstein Registration No. 25,665 Substitute for Form 1449 A & B/PTO

Sheet

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

of

Complete if Known				
Application Number	10/519,084			
Confirmation Number	7332			
Filing Date	December 23, 2004			
First Named Inventor	Heiji WATANABE	,,,		
Art Unit	2822			
Examiner Name	Tsz K. CHIU			
Attorney Docket Number	Q85504			

U.S. PATENT DOCUMENTS						
Examiner Initials*	Cite No.1	Document		Publication Date MM-DD-YYYY		
		Number	Kind Code ² (if known)		Name of Patentee or Applicant of Cited Documen	
		US				
		US				
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FOREIGN PATENT DOCUMENTS							
Examiner Cite Initials* No.1	Cite	Foreign Patent Document			Publication Date	Name of Patentee or	
		Country Code ³	Number ⁴	Kind Code ⁵ (if known)	MM-DD-YYYY	Applicant of Cited Document	Translation ⁶
		JP	2000-195856	A	07-14-2000		
		JP	2005-534163	A	11-10-2005		
		JP	2003-282873	A	10-03-2003		
		JP	2003-8005	A	01-10-2003	Matsushita Electric Inc. Co. Ltd	
	,	JP	2000-3885	A	01-07-2000	Lucent Technology Inc.	
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NON PATENT LITERATURE DOCUMENTS				
Examiner Initials*				
		Hyungsuk Jung et al., Electrical and Reliability Characteristics of a n U1trastjom TaOxNy Gate Deielectric Prepared by ND3 Annealing of Ta205, IEEE Electron Device Letters, December 2000, Vol. 21, No. 12, pp. 563-565		

	 	
Examiner Signature	Date Considered	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹Applicant's unique citation designation number (optional). ²See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or follow the hyperlink from the title of the document to the intranet. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to indicate here if English language Translation is attached.